2017
BluGlass Annual General Meeting

MONDAY 13 NOVEMBER 2017



OUR VISION

Creating a brighter future, through the impacts of lower temperature RPCVD





THE RPCVD BREAKTHROUGH

RPCVD - Remote Plasma Chemical Vapour Deposition





Lower temperature manufacturing processes



Lower **cost** inputs

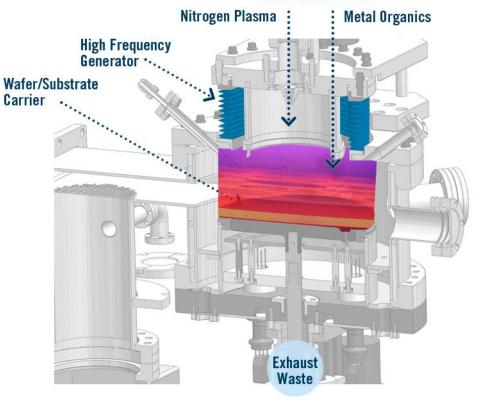


Higher performing devices



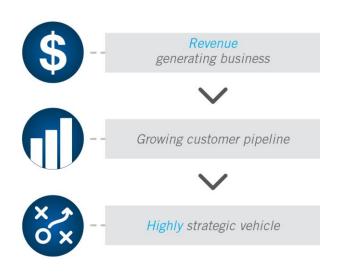
More Environmentally friendly & sensitive

PRECISE GAS FLOW

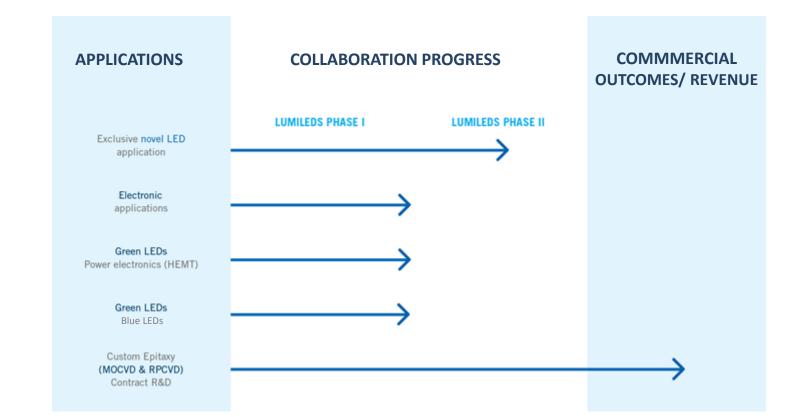


INTRODUCING EPIBLU





PROGRESS TOWARDS COMMERICALISATION













THE YEAR AHEAD



Complete industry evaluations





Select more partners/collaborators



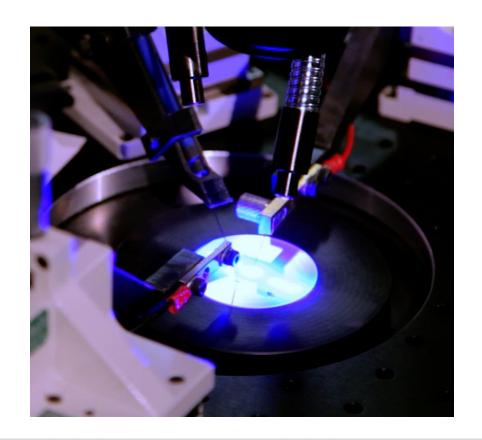


Generate and protect more IP





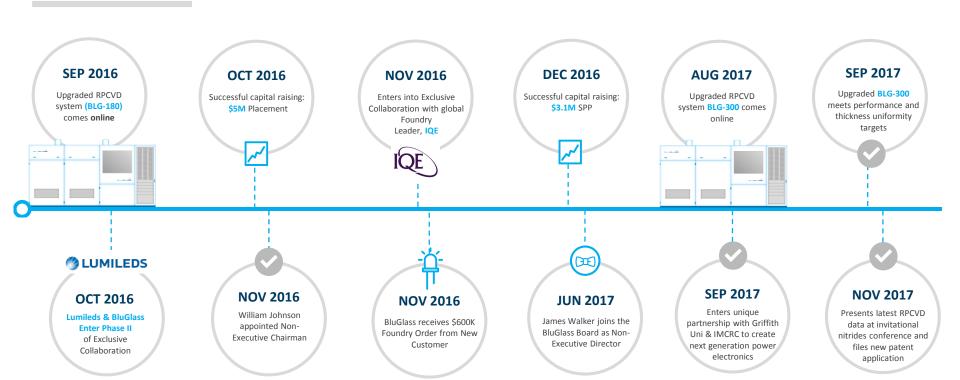
Achieve commercial outcome





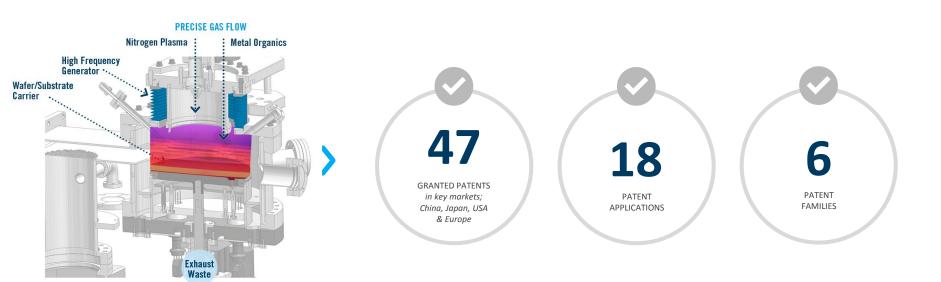
2017 HIGHLIGHTS

BluGlass has made significant technical progress in bringing RPCVD towards commercialisation



IP PORTFOLIO

Hardware & Process Patents



FINANCIAL PERFORMANCE

CURRENT POSITION

FORECAST POSITION





BluGlass has a robust cash position to deliver initial commercialisation outcomes

2.5YRS CASH RUNWAY



LUMILEDS COLLABORATION - PHASE II PROGRESS

Exclusive collaboration agreement with market leader—device manufacturer



PARTNERSHIP WITH WORLD LEADING LED COMPANY TO DEVELOP NOVEL LED APPLICATIONS

RPCVD EVALUATION

collaboration is focused on a novel application of RPCVD for LEDs

Phase I Complete

~

Phase II progressing well

STATUS

Phase II is working to integrate BluGlass' RPCVD technology into certain Lumileds LED applications Lumileds and BluGlass
are both pleased with the progress of
Phase II and are confident in the project
achievement



IQE COLLABORATION

Strategic Partnership with world leading foundry manufacturer of advanced semiconductor wafer products to the

global semiconductor industry



IQE

PARTNERSHIP WITH WORLD LEADING FOUNDRY TO DEVELOP A RANGE OF ELECTRONIC APPLICATIONS

Exclusive Collaboration Agreement to co-develop nitride films for a range of electronic devices on both silicon and IQE's cREO™ technology using BluGlass' unique low temperature RPCVD technology

IQE products are used by major global chip companies to produce the high performance components that enable a wide range of high-tech applications including for the wireless industry

Positive collaboration is ongoing and both companies remain committed to achieving the technology goals



VEECO & HC SEMITEK EVALUATIONS – RECENTLY RECOMMENCED



RPCVD EVALUATION WITH WORLDS LARGEST MOCVD EQUIPMENT MANUFACTURER



LEADING CHINESE
LED COMPANY EXPLORING RPCVD
FOR MULTIPLE APPLICATIONS

RPCVD EVALUATION

STATUS

Positive initial 2 inch trials for green LEDs







Recently upgraded BLG-300 with uniformity over 4 & 6" wafers has enabled this evaluation to recommence

RPCVD EVALUATION

STATUS

Targeting enhanced performance and lower cost LEDs using RPCVD



Recently upgraded BLG-300 with uniformity over 4 & 6" wafers has enabled this evaluation to recommence



EPIBLU – CUSTOM EPITAXY SERVICE BUSINESS

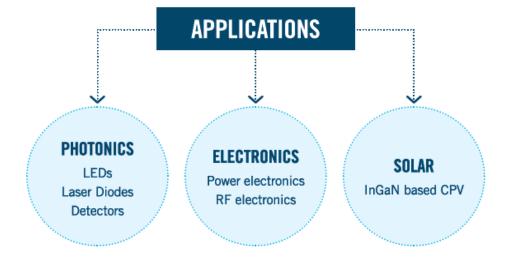




Growing pipeline of new customers

Providing both MOCVD & RPCVD services

Conducting services for green and blue LEDs, power electronics, and laser diodes



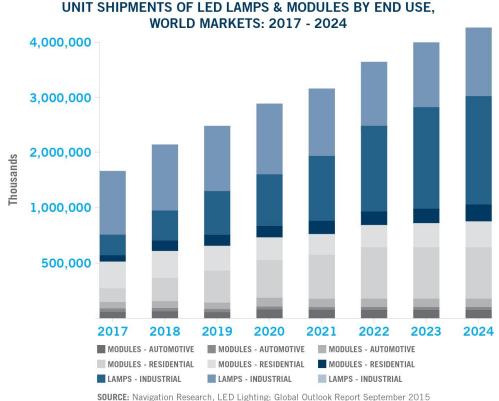
END MARKETS LED

10.4%

The LED market is expected to experience *CAGR of* **10.4%** through to 2025



Source: Research and Markets Report Global Light-Emitting Diodes (LED) Market Analysis & Trends - Industry Forecast to 2025; and Navigant Research



SOURCE: Navigation Research, LED Lighting: Global Outlook Report September 2015

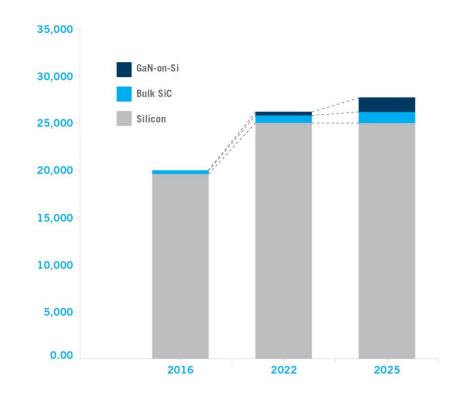
END MARKETS POWER ELECTRONICS

The Power Electronics markets also presents a growing opportunity for the RPCVD technology

\$2.6B
The GaN and SiC
power electronics
market is expected to
be worth \$2.6B by
2022

GaN for power semiconductors is expected to grow at

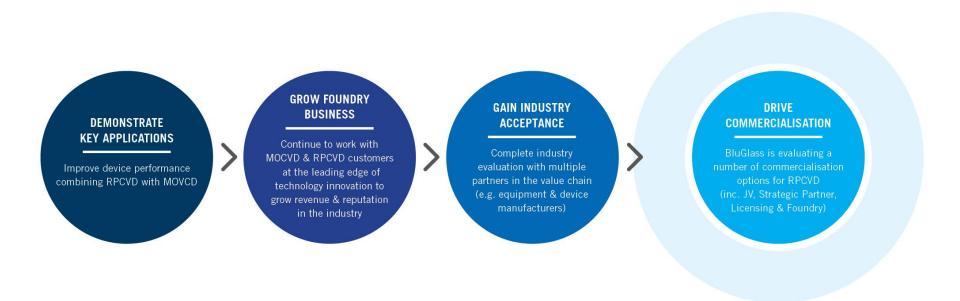
~90% CAGR



Source: Stifel, Sep 2017; and Research and Markets

PATH TO MARKET

BluGlass continues to be active in all four segments of its path to market



CONCLUSION INVESTMENT HIGHLIGHTS



Disruptive platform technology



LED,

Power &

Multiple, growing end markets



Well funded, approaching commercialisation



Sales from

Services

High end service capability



A team with global leading expertise in semiconductors



Multiple awards & grants



LUMILEDS PHASE II AND OTHER INDUSTRY COLLABORATIONS



Lumileds pleased with progress and are committed to project



A number of iterations of BluGlass wafers have been fabricated at Lumileds



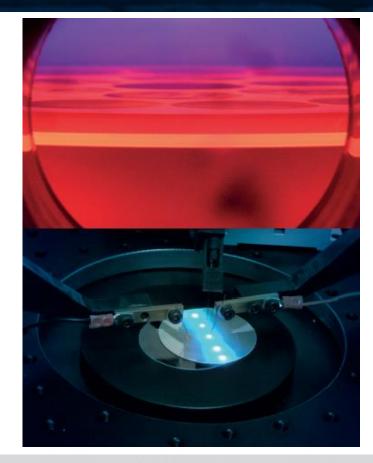
Both RPCVD systems with the latest chamber design are delivering on technical roadmap for Lumileds project



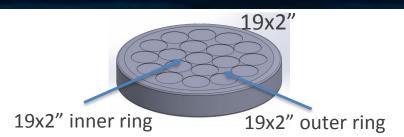
HC Semitek, IQE, and Veeco collaborations are all recommencing with the success of the upgraded BLG-300 RPCVD capability



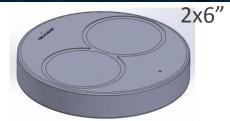
BluGlass has filed a patent

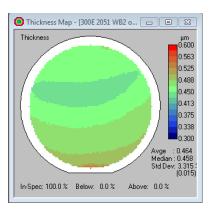


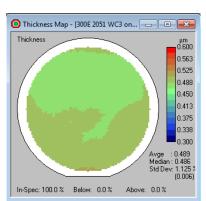
BLG-300 RPCVD CHAMBER UPGRADE – THICKNESS UNIFORMITY IMPROVEMENT

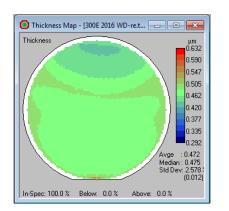


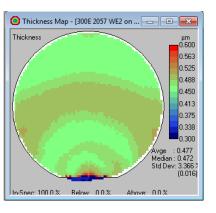












WAFER DIAMETER	2" (OUTER)	2" (INNER)	100 mm	150 mm
2017 CHAMBER (THICKNESS STD DEV %)	1.1	3.3	2.6	3.4
2016 CHAMBER (THICKNESS STD DEV %)	6.8	7.8	10.9	

BLUGLASS CUSTOM EPITAXIAL SERVICES





Targeting strategic customers requiring both RPCVD and MOCVD combined



BluGlass has repeat customers developing applications in both LEDs and Laser Diodes



BluGlass has enhanced several demonstrators using our in-house RPCVD and MOCVD capabilities to market to the industry



Recently showcased several **Key Demonstrators** at the recent semiconductor conference



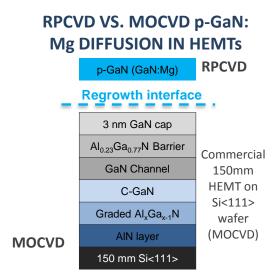
RPCVD TECHNOLOGY DEVELOPMENT AREAS

RPCVD DIFFERENTIATOR	BLUE LEDS	GREEN LEDS	LASER DIODES	RGB MICRO - LEDS AND SOLAR	UV LEDS	POWER ELECTRONICS	ELECTRONICS APPLICATIONS
p-GaN	•	••	••	•		••	
p-AlGaN	•	•	••	•	•		
InGaN	•	•	•	•			
AIN / Silicon							••
AIN / sapphire	••				•		

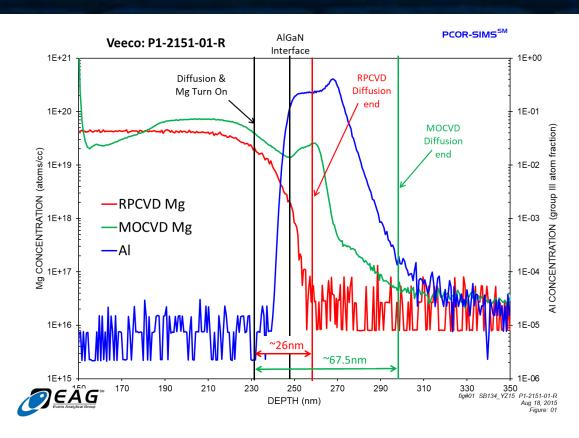
BluGlass active collaborations and/or customers

BluGlass actives areas in discussions with potential collaborators and/or customers

RPCVD p-GaN FOR E-MODE HEMTs — COLLABORATION WITH VEECO



Note the Mg SIMS trace for the MOCVD growth is overlayed on the RPCVD p-GaN on HEMT SIMS trace for ease of comparison. The Al traces from the 2DEG (common to both structures) was used for alignment purposes.



LED STRUCTURE GROWN USING MOCVD

p-GaN GROWN USING RPCVD

p-GaN grown at INTERMEDIATE

to HIGH temperature

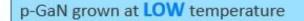
Multi-Quantum-Well (MQW) InGaN layer, the ACTIVE REGION of an LED grown at low temperature



n-GaN grown at high temperature

GaN grown at high temperature

Sapphire Substrate





Multi-Quantum-Well (MQW) InGaN layer, the ACTIVE REGION of an LED – grown at low temperature



n-GaN grown at high temperature

GaN grown at high temperature

Sapphire Substrate

AOCVE

KEY DEMONSTRATOR: RPCVD p-GaN + MOCVD FOR GREEN LEDs

2016 AGM DATA

MOCVD* EL DATA	20 mA
Light Output (mW)	1.3
V _f (V)	3.5
Peak Wavelength (nm)	525
FWHM (nm)	35

RPCVD* EL DATA	20 mA	
Light Output (mW)	1.6	
V _f (V)	3.9	
Peak Wavelength (nm)	525	
FWHM (nm)	33	

% Performance improvement of

RPCVD compared to MOCVD +10%

[Light Output / (I x Vf)]

2017 DATA**

MOCVD EL DATA	20 mA	50 mA	100 mA
Light Output (mW)	1.3	3.3	6.2
V, (V)	3.1	3.7	4.6
Peak Wavelength (nm)	514	511	508
FWHM (nm)	28	31	33

RPCVD EL DATA	20 mA	50 mA	100 mA
Light Output (mW)	1.9	4.5	8.1
V, (V)	3.0	3.6	4.5
Peak Wavelength (nm)	515	512	510
FWHM (nm)	30	30	33

% Performance improvement of RPCVD compared to MOCVD [Light Output / (i x Vf)]

+47% +39% +35%

** Both RPCVD and MOCVD data obtained from p-GaN overgrown on the same partial LEDs grown by MOCVD up to and including the EBL. All measurements taken at wafer level using indium dot contacts.



^{*} MOCVD data from best results for complete LED structure grown without any interruption and using a p-AlGaN EBL. RPCVD data taken from best results overgrown on equivalent MOCVD-grown MQWs. RPCVD samples do not contain an EBL. All measurements taken at wafer level using indium dot contacts.

LED STRUCTURE GROWN USING MOCVD

p-GaN & MQW GROWN USING RPCVD

p-GaN grown at **INTERMEDIATE**

to HIGH temperature



Multi-Quantum-Well (MQW) InGaN layer, the ACTIVE REGION of an LED – grown at low temperature



n-GaN grown at high temperature

GaN grown at high temperature

Sapphire Substrate





Multi-Quantum-Well (MQW) InGaN layer, the *ACTIVE REGION* of an LED – grown at low temperature



n-GaN grown at high temperature

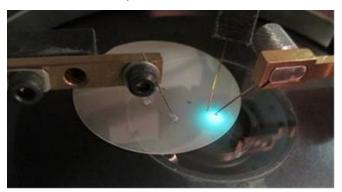
GaN grown at high temperature

Sapphire Substrate



KEY DEMONSTRATOR: RPCVD MQWs for RGB LEDs

RPCVD MQW BASED LED 2016



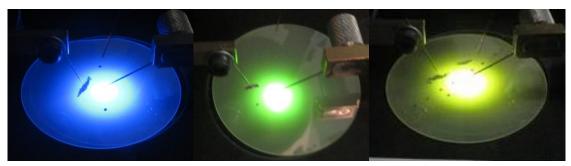


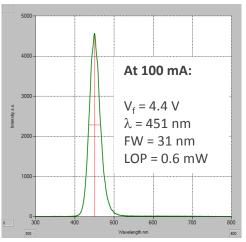
To attract further industry interest BluGlass continues to enhance the RPCVD capability



Low temperature RPCVD is favourable for In rich InGaN MQWs useful for longer wavelength LEDs

RPCVD MQW BASED LEDs 2017







Micro-LED players have shown interest in RPCVD capability for blue, green, yellow and red LEDs for display and other applications

KEY DEMONSTRATOR: RGB RPCVD FOR MICRO-LEDS AND SOLAR APPLICATIONS

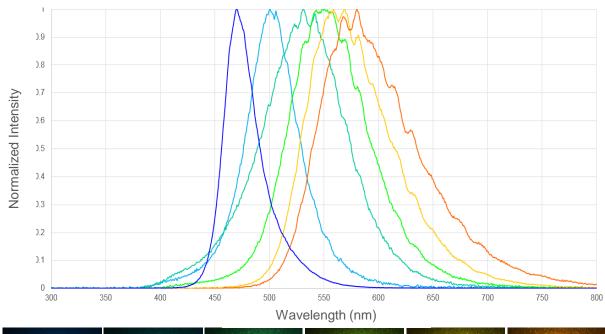


Preliminary RPCVD demonstration of RGB LED capability



RPCVD MQW capability is also a key step to the realisation of high efficiency solar cells through multi junction architecture

EL SPECTRA OF LEDs GROWN USING RPCVD MQWS

















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